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APPLICANT

Calvin T. Gabriel et al.

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(Use several sheets if necessary)

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03/28/2001

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1756. 1746

U.S. PATENT DOCUMENTS

EXAMINER INITIAL	REF	DOCUMENT NUMBER	DATE	NAME	CLASS AUG 01 2001	SUB- CLASS	FILING DATE IF APPROPRIATE
		09/819,342		Shields et al			03/28/01
		09/819,344		Okoroanyanwu et al			03/28/01
		09/819,552		Gabriel et al			03/28/01
		09/819,692		Okoroanyanwu et al			03/28/01
		09/820,143		Okoroanyanwu et al			03/28/01
WS		6,107,172	08/22/00	Yang et al	438	585	
WS		6,103,457	08/15/00	Gabriel	430	318	
WS		5,965,461	10/12/99	Yang et al	438	717	
WS		5,003,178	03/26/91	Livesay	250	492.300	

FOREIGN PATENT DOCUMENTS

	REF	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUB- CLASS	TRANSLATION	
							YES	NO

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

WS		Livesay, W. R., "Large-area electron-beam source," Journal of Vacuum Science & Technology B, Vol. 11, No. 6, Nov./Dec. 1993, pp. 2304-2308, American Vacuum Society
WS		Yang, J. J. et al, "Electron Beam Processing for Spin-on Polymers and its Applications to Back-End-of-Line (BEOL) Integration," Materials Research Society Symposium Proceedings, Vol. 511, 1998, pp. 49-55, Materials Research Society
WS		Ross et al, "Plasma Etch Characteristics of Electron Beam Processed Photoresist," The Society of Photo-Optical Instrumentation Engineers, Vol. 2438, 1995, pp. 803-816, SPIE-The International Society for Optical Engineering
WS		Grün, Von A. E., "Lumineszenz-photometrische Messungen der Energieabsorption im Strahlungsfeld von Elektronenquellen Eindimensionaler Fall in Luft," Zeitschrift für Naturforschung, Vol. 12a, 1957, pp. 89-95, Publisher: Zeitschrift für Naturforschung; full English Translation attached (11 pgs.)

EXAMINER

WS egan

DATE CONSIDERED

8/21/01

* EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include any copy of this form with next communication to applicant.